Electronic Acknowledgement Receipt				
EFS ID:	1152742			
Application Number:	10754321			
Confirmation Number:	7484			
Title of Invention:	Integrated phase angle and optical critical dimension measurement metrology for feed forward and feedback process control			
First Named Inventor:	Alfred W. Mak			
Customer Number:	44257			
Filer:	Keith Patrick Taboada			
Filer Authorized By:				
Attorney Docket Number:	AMAT/8428/MASK/MASK-ETCH/			
Receipt Date:	14-AUG-2006			
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File Listing:

Document Number	Document Description	File Name	File Size(Bytes)	Multi Part	Pages
1		8428_EFROA_V1.pdf	350882	yes	9

	Multipart Description			
	Doc Desc	Start	End	
	Amendment After Final	1	1	
	Claims	2	5	
	Applicant Arguments/Remarks Made in an Amendment	6	9	
Warnings:		-		
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New Applications Under 35 U.S.C. 111

If a new application is being filed and the application includes the necessary components for a filing date (see 37 CFR 1.53(b)-(d) and MPEP 506), a Filing Receipt (37 CFR 1.54) will be issued in due course and the date shown on this Acknowledgement Receipt will establish the filing date of the application.

National Stage of an International Application under 35 U.S.C. 371

If a timely submission to enter the national stage of an international application is compliant with the conditions of 35 U.S.C. 371 and other applicable requirements a Form PCT/DO/EO/903 indicating acceptance of the application as a national stage submission under 35 U.S.C. 371 will be issued in addition to the Filing Receipt, in due course.